# Analysis of optical properties of solar energy materials Comices 'Energie solaire' - Namur - 23/04/2012

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#### Outline of the presentation

Introduction and experimental techniques

Optical properties of materials Spectroscopic ellipsometry

Materials for thermal applications Coatings for solar absorbers

Materials for photovoltaïc applications

Organic materials Dielectric matrices and metal nanoparticles

Smart materials with tunable optical properties

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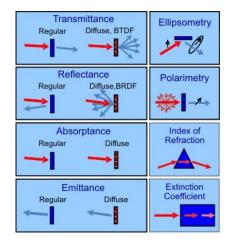
Resume and conclusions

# Optical properties of materials

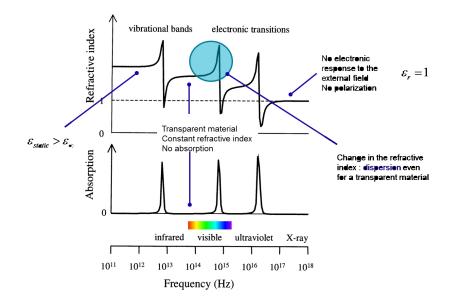
- Optical processus in materials : reflexion, propagation, transmission
- Propagation modes : refraction, absorption and luminescence, diffusion (elastic or inelastic)
- Restricted (and more precise) meaning : complex frequency dependent refractive index or dielectric tensor

$$\tilde{\epsilon}(\omega) = [n(\omega) - j k(\omega)]^2$$
  
 $\alpha(\omega) = \frac{4\pi}{\lambda}k(\omega)$ 

 Need for absolute experimental methods



### What in which spectral range?



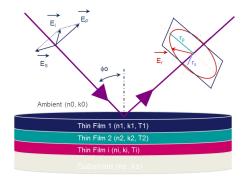
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# Ellipsometry : a powerful tool to probe layer thickness and optical properties



Paul Karl Ludwig Drude (1863-1906)

Different behavior of two light beams with orthogonal polarizations after reflexion (1890)



$$ho = an \Psi e^{i\Delta}$$
 $an \Psi = rac{|R_p|}{|R_s|} \quad an \Delta = \delta_p - \delta_s$ 

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# Spectroscopic ellipsometry at UMONS and MATERIA NOVA



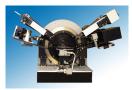
Rudolph Auto EL III SWE



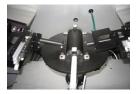
Rudolph S2000 SE



SOPRA GESP5 NUV-VIS-NIR (2001)



SOPRA FTIR-SE (2003)



SOPRALAB ellipsometric porosimeter (2009)



ACCURION Imaging Ellipsometer (03/2012)

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Overall spectral range : 250 nm – 18000 nm with control of temperature (-196 K – 650 K), determination of nano- and mesoporosity and spacial resolution better than 1 micron

Optical properties of nickel-chromium oxide layers

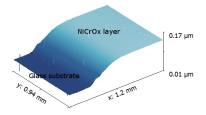
Importance of NiCrO<sub>x</sub> :

- Interest in solar absorbers manufacturing
- High absorbance
- Good stability in a wide range of oxidizing/reducing environments
- High thermal resistance

#### Materials and methods :

- Films deposited by magnetron sputter deposition (Materia Nova) on glass substrates
- Roughness by optical profilometry
- Optical properties in VIS-NIR (350 - 1700 nm) and mid-IR (600 - 6000 cm<sup>-1</sup>) by SE analysis

Optical properties of nickel oxide chromium thin films as a function of their chemical composition



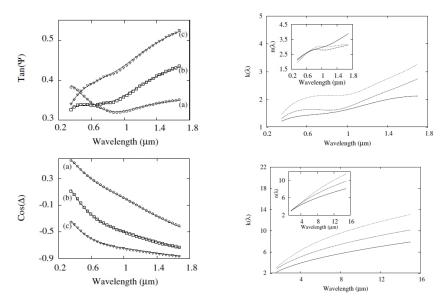
Optical profilometry of a  $\simeq 170$  nm-thick NiCrO<sub>x</sub> film on model substrate (glass) [Magn. 5x – Area : 0.94 mm  $\times$  1.2 mm]

• Roughness parameters  $\leq 1 \text{ nm}$ 

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 One-layer model for SE data modeling

# Optical properties of nickel-chromium oxide layers



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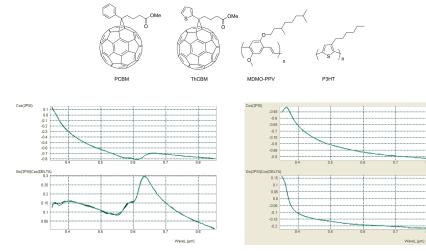
#### Optical properties of nickel-chromium oxide layers

- Optical modeling with non-interacting Lorentzian oscillators and Drude term for conductivity in the IR range
- Importance of the metal-oxide transition
- Equivalence between electrical conductivity (4-points method) and optical conductivity (FTIR-SE results)

Samples	$O_2$ (%)	4PPT	FTIR-SE	Diff (%)
NiCrO <sub>x</sub> -02	20	32.8	$34.2\pm3.8$	4.1
NiCrO <sub>x</sub> -03	25	54.5	$54.1\pm1.0$	0.7
NiCrO <sub>x</sub> -04	30	88.0	$82.2\pm6.6$	7.0

**Table 2** Optical resistivity  $(\Omega/square)$  of the NiCrO<sub>x</sub> films. Comparison between FTIR-SE and 4PPT values.

### Materials for organic solar cells (OPV) : P3HT-PCBM

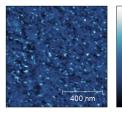


Ellipsometric spectra (Green : data – Blue : fit results) of a 55 nm-thick P3HT film on silicon substrate Ellipsometric spectra (Green : data – Blue : fit results) of a 21 nm-thick PCBM film on silicon substrate Optical response of dielectric matrices embedding silver nanoparticles

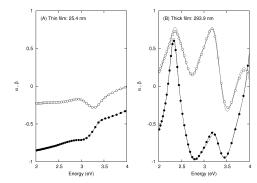
- Importance of noble metal nanoparticles (embedded or localized at interfaces) or of metallic gratings to enhance solar light absorption using plasmonic modes
- Polyvinyl-alcohol (PVA) films (20 nm) with high silver content (25% AgNO<sub>3</sub>)

7.1 nm

0.0 nm



Topography AFM image (non-contact mode) of a 25 nm-thick film

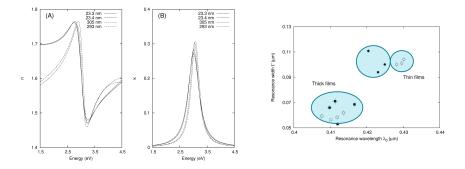


Spectroscopic ellipsometry data (symbols) and fit results (lines) for (A) thin and (B) thick films

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#### Optical response of dielectric matrices embedding silver nanoparticles

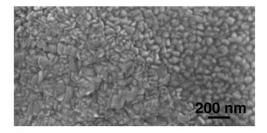
- Polymer films (PVA) embedding silver nanoparticles : behavior of thin and thick films at low (2.5%, open symbols) and high (12.5%, plain symbols) doping levels
- Significant difference in the refractive index of thin and thick films at high constant doping levels
- Need for modeling beyond the classical effective media theories (Bruggeman) : island models ('optical percolation')



 Smart materials with tunable optical properties for control of the solar reflectance/transmittance

Vanadium VO<sub>2</sub> :

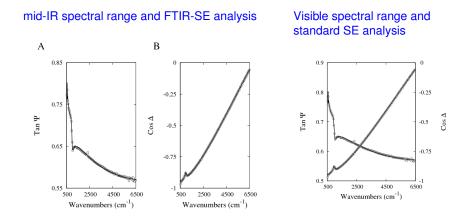
- > Thermochromic material with tunable transition temperature (doping)
- Oxyde–Metal transition



(Lafort et al, Thin Solid Films 2011)

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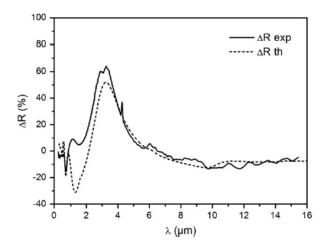
#### Vanadium oxide : SE data and fit results



#### SE data for a 200 nm-thick VO<sub>2</sub> film

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# Vanadium oxide : reflexion contrast in the VIS-NIR and MidIR spectral domains



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### Vanadium oxide

#### 100-nm thick VO<sub>2</sub> film on stainless steel substrate Local information required on optical properties : IMAGING ELLIPSOMETRY



Delta 0 20 180.0 40 -60 -80 -100 -120 -140 -160 --158.8 160 -180 200 -220 --137.6240 -260 -285 250 300 369 50 100 150 200 microns -116.5

White light image (polarization mode)  $\rightarrow$  : structural information and contours

Imaging ellipsometry data ( $\Delta$  image)  $\rightarrow$ : optical properties at the micron scale but increa sing number of data (hypercube) Multivariate analysis methods required

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### Resume and conclusions

#### Resume

- Non-destructive analysis of optical properties
- Large spectral domain covered by spectroscopic ellipsometry
- Determination of porosity, temperature effects and local effects at the (sub)micron scale

#### Conclusions

- Experimental technique suitable for investigating the optical bahavior of solar energy materials (solar absorbers, PV-OLED, smart materials ...)
- Need of advanded models for metallic layers, metal-oxide transition and link between AFM and ellipsometric roughness parameters

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Thank you for your attention ! Questions ?

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